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Bib Data Sheet

CONFIRMATION NO. 8489

SERIAL NUMBER 10/646,467	FILING OR 371(c) DATE 08/22/2003 RULE	CLASS 438	GROUP ART UNIT 2812	ATTORNEY DOCKET NO. 006915/P6
APPLICANTS Kenneth S. Collins, San Jose, CA; Hiroji Hanawa, Sunnyvale, CA; Kartik Ramaswamy, Santa Clara, CA; Andrew Nguyen, San Jose, CA; Amir Al-Bayati, San Jose, CA; Biagio Gallo, Los Gatos, CA; Gonzalo Antonio Monroy, San Francisco, CA;				
** CONTINUING DATA * <i>Al</i> This application is a CIP of 10/164,327 06/05/2002 PAT 6,939,434 which is a CIP of 09/636,435 <i>Al</i> 08/11/2000 PAT 6,494,986 <i>Al</i>				
** FOREIGN APPLICATIONS * <i>Al</i>				
IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** 11/14/2003				
Foreign Priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no 35 USC 119 (a-d) conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no <input type="checkbox"/> Met after allowance		STATE OR COUNTRY CA	SHEETS DRAWING 85	TOTAL CLAIMS 85
Verified and Acknowledged Examiner's Signature <i>[Signature]</i> Initials <i>[Initials]</i>		INDEPENDENT CLAIMS 1		
ADDRESS Patent Counsel, M/S 2061 Legal Affairs Dept. Applied Materials, Inc. P.O. Box 450-A Santa Clara, CA95035				
TITLE Plasma immersion ion implantation process using an inductively coupled plasma source having low dissociation and low minimum plasma voltage				
FILING FEE RECEIVED 2090	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:		<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit	